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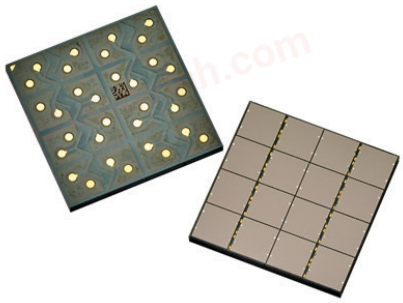
BROADCOM®

Data Sheet

AFBR-S4N44P164M

4×4 NUV-MT Silicon Photo Multiplier Array



Description

The Broadcom® AFBR-S4N44P164M is a 4×4 silicon photo multiplier (SiPM) array used for ultra-sensitive precision measurements of single photons. This SiPM is based on the NUV-MT technology, which combines improved photo-detection efficiency (PDE) with decreased dark count rate and reduced crosstalk compared to the NUV-HD technology. The pitch of SiPMs is 4 mm in both directions. Larger areas can be covered with a pitch of 16 mm by tiling multiple AFBR-S4N44P164M arrays almost without any edge losses. The encapsulation for good mechanical stability and robustness is realized by an epoxy clear mold compound, which is highly transparent down to UV wavelengths, resulting in a broad response in the visible light spectrum with high sensitivity toward the blue and near-UV region of the light spectrum. The array is best suited for the detection of low-level pulsed light sources, especially for detection of Cherenkov or scintillation light from the most common organic (plastic) and inorganic scintillator materials (for example, LSO, LYSO, BGO, NaI, CsI, BaF, $LaBr_3$). This product is lead-free and compliant with RoHS.

Features

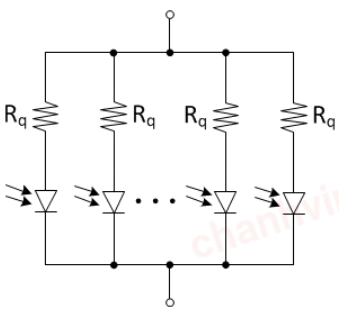
- 4×4 SiPM array
- Array size 16.00 mm × 16.00 mm
- High PDE (63% at 420 nm)
- Excellent SPTR and CRT
- Excellent uniformity of breakdown voltage
- Excellent uniformity of gain
- 4-side tileable, with high fill factors
- Cell pitch 40 µm
- Highly transparent epoxy protection layer
- Operating temperature range from –20°C to +50°C
- RoHS, CFM, and REACH compliant

Applications

- X-ray and gamma ray detection
- Nuclear medicine
- Positron emission tomography
- Safety and security
- Physics experiments
- Cherenkov detection

Block Diagram

Figure 1: AFBR-S4N44P164M Block Diagram of Single SiPM Element



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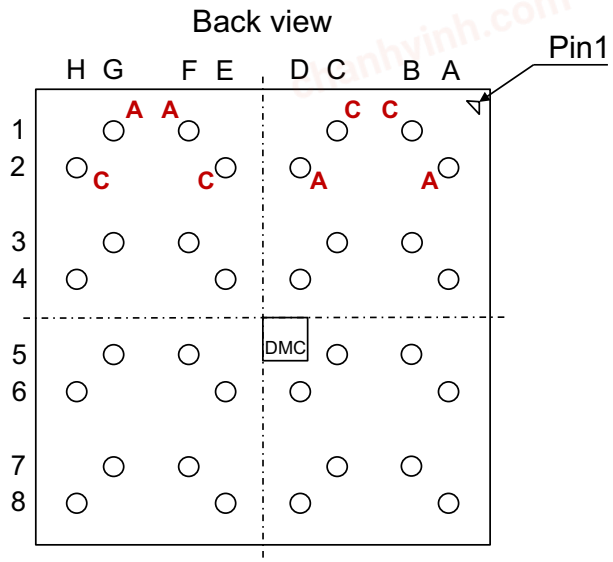
Pad Layout

The AFBR-S4N44P164M has 32 signal pins. The anode and the cathode of each SiPM chip can be connected separately. The cathodes do not have a common connection on the module. Figure 2 shows the pad layout, and Figure 3 shows the recommended landing pattern.

Figure 2: Pad Layout

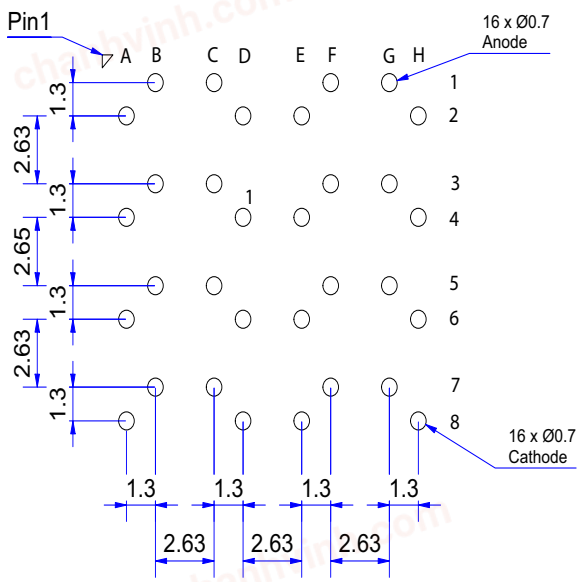


Pin	Channel, Electrode	Pin	Channel, Electrode
A2	Ch. 1, Anode	E2	Ch. 3, Cathode
A4	Ch. 5, Anode	E4	Ch. 7, Cathode
A6	Ch. 9, Anode	E6	Ch. 11, Cathode
A8	Ch. 13, Anode	E8	Ch. 15, Cathode
B1	Ch. 1, Cathode	F1	Ch. 3, Anode
B3	Ch. 5, Cathode	F3	Ch. 7, Anode
B5	Ch. 9, Cathode	F5	Ch. 11, Anode
B7	Ch. 13, Cathode	F7	Ch. 15, Anode
C1	Ch. 2, Cathode	G1	Ch. 4, Anode
C3	Ch. 6, Cathode	G3	Ch. 8, Anode
C5	Ch. 10, Cathode	G5	Ch. 12, Anode
C7	Ch. 14, Cathode	G7	Ch. 16, Anode
D2	Ch. 2, Anode	H2	Ch. 4, Cathode
D4	Ch. 6, Anode	H4	Ch. 8, Cathode
D6	Ch. 10, Anode	H6	Ch. 12, Cathode
D8	Ch. 14, Anode	H8	Ch. 16, Cathode

NOTE:

1. Dimensions: mm.
2. “A” stands for anode, and “C” stands for cathode.

Figure 3: Recommended Landing Pattern



NOTE: Dimensions are in millimeters.

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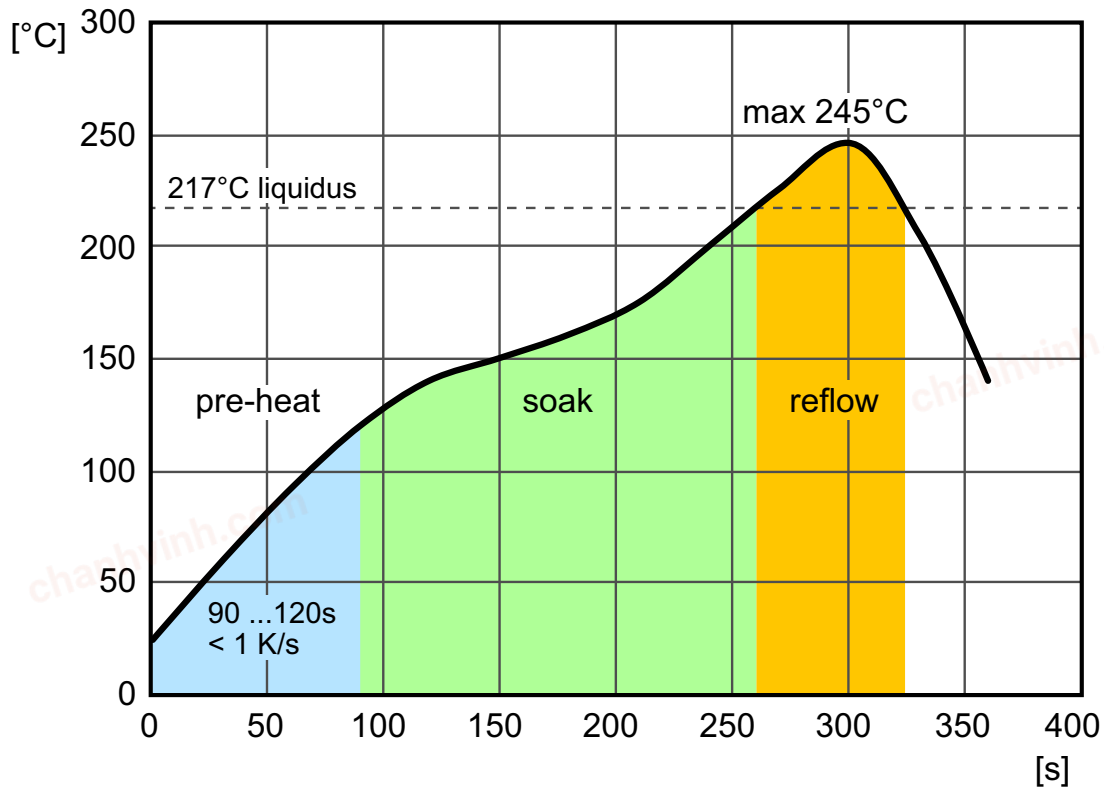
Regulatory Compliance Table

Feature	Test Method	Performance
Electrostatic discharge (ESD) to the electrical pins, human-body model (contact ESD)	JESD22-A114	See Absolute Maximum Ratings.
Electrostatic discharge (ESD) to the electrical pins, charged-device model	JESD22-C101F	See Absolute Maximum Ratings.
Restriction of hazardous substances directive	RoHS Directive 2011/65/EU Annex II	Certified compliant.

Reflow Soldering Diagram

Figure 4: Recommended Reflow Soldering Profile



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Absolute Maximum Ratings

Stresses in excess of the absolute maximum ratings can cause damage to the devices. Limits apply to each parameter in isolation. Absolute maximum ratings are those values beyond which damage to the device may occur if these limits are exceeded for other than a short period of time.

Parameter	Symbol	Min.	Max.	Unit
Storage Temperature	T_{SG}	–20	+60	°C
Operating Temperature[a]	T_A	–20	+50	°C
Soldering Temperature[b, c]	T_{SOLD}	—	245	°C
Lead Soldering Time[b, c]	t_{SOLD}	—	60	seconds
Electrostatic Discharge Voltage Capability HBM	ESD_{HBM}	—	2	kV
Electrostatic Discharge Voltage Capability CDM	ESD_{CDM}	—	500	V
Operating Over Voltage	V_{OV}	—	16	V

a. Biased at constant voltage = 12V above breakdown.

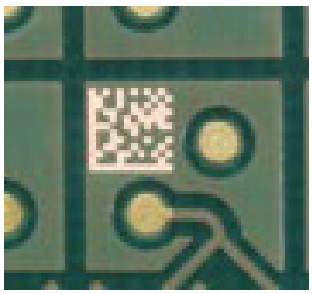
b. The tile is reflow solderable according to the solder diagram shown in Figure 4.

c. Baking at 125°C for 16 hours is mandatory prior to soldering. MLD is according to MSL 6 with a floor life of 4 hours at 30°C and 60% relative humidity.

Device Identification

Each device can be identified and tracked by a unique data matrix code (DMC) on the back of the PCB. The code is structured as follows: YYWWNNNNNN (Y – year, W – week, N – running number). Figure 5 shows an example DMC.

Figure 5: Example Data Matrix Code for Tile Identification



Single Device Specification

Features are measured at 25°C unless otherwise specified.

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Geometric Features

Parameter	Symbol	Value	Unit
Single device area	DA	3.84 × 3.74	mm^2
Active area	AA	3.72 × 3.62 × 16	mm^2
Element active area	EAA	3.72 × 3.62	mm^2
Micro cell pitch	L_{CELL}	40	µm
Number of micro cells per element	N_{CELLS}	8334	—

Optical and Electrical Features

Features are measured at 12V OV and 25°C unless otherwise specified.

Parameter	Symbol	Min.	Typ.[a]	Max.	Unit	Reference Plots
Spectral range	λ	300	—	900	nm	Figure 6
Peak sensitivity wavelength	λ_{PK}	—	420	—	nm	Figure 6
Breakdown voltage	V_{BD}	32	32.5	33	V	Figure 8
Temperature coefficient of breakdown voltage	$\Delta V_{BD}/\Delta T$	—	30	—	mV/°C	—
Photo-detection efficiency[b]	PDE	58	63	—	%	Figure 6, Figure 7
Dark current per element	I_D	—	3.3	19	µA	Figure 8
Dark count rate per element[c]	DCR	—	1.7	7.5	Mcps	Figure 9
Dark count rate per unit area	DCR_{mm2}	—	125	650	$kcps/mm^2$	—
Gain	G	6.0	7.3	8.5	$\times 10^6$	Figure 10
Optical crosstalk	P_{XTALK}	—	23	30	%	Figure 11
After-pulsing probability	P_{AD}	—	< 1	5	%	—
Recharge time constant	T_{FALL}	—	55	—	ns	Figure 12
Nominal terminal capacitance[d]	C_T	—	580	—	pF	—
Temperature coefficient of gain[e]	$\Delta G/\Delta T$	—	1.46	—	$\times 10^4$/°C	—

a. Measured at 12V OV.

b. Measured at peak sensitivity wavelength. The measurement does not include correlated noise, such as after-pulsing or optical crosstalk.

c. Measured at 0.5 p.e. amplitude. The measurement does not include delayed correlated events.

d. Measured using the input sine wave with f = 200 kHz and Vin = 500 mV.

e. Calculated from the gain dependence on V and the breakdown voltage temperature coefficient: $dG/dT = dG/dV \times dV_{BD}/dT$.

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Reference Plots

Features are measured at 25°C unless otherwise specified. The plotted data represents typical values per single element.

Figure 6: PDE vs. Wavelength

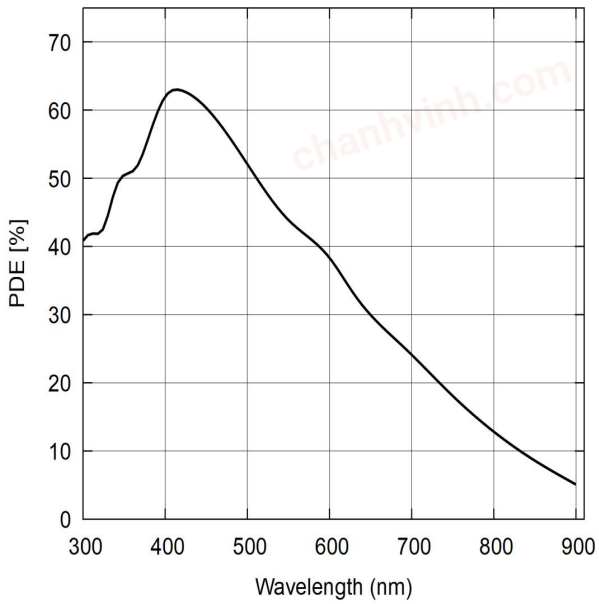

Figure 7: PDE at Peak λ vs. OV (Overmolded Package)

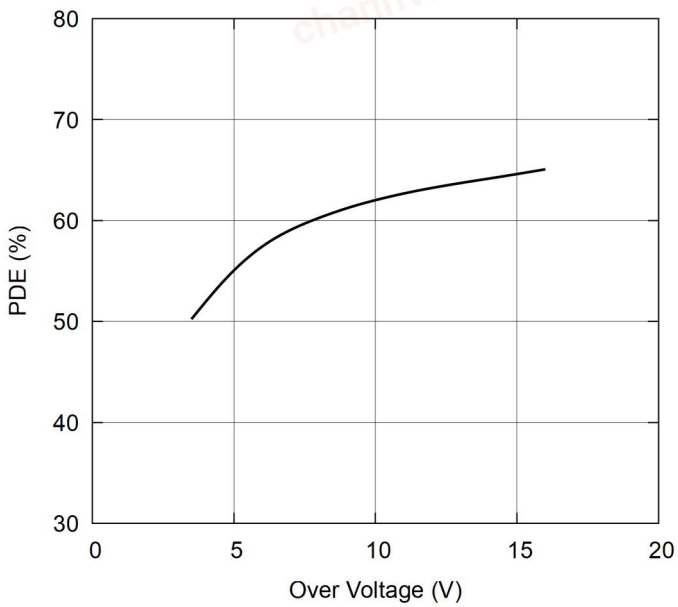

Figure 8: Reverse IV Curve

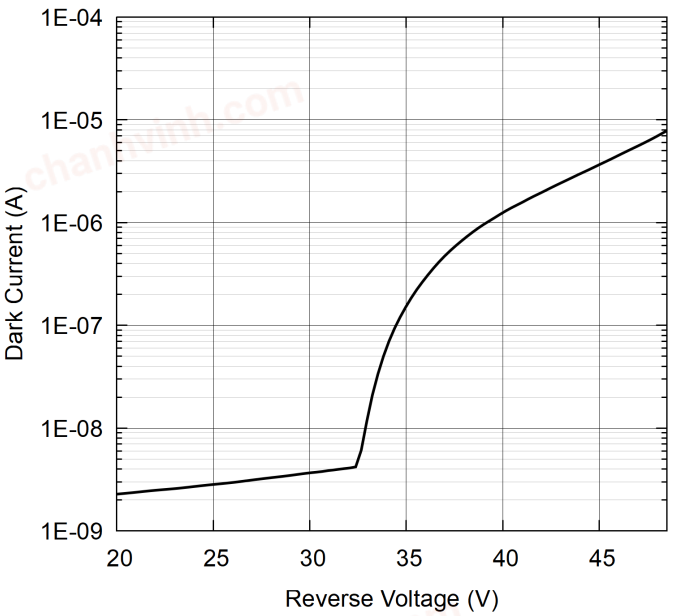

Figure 9: Dark Count Rate vs. OV

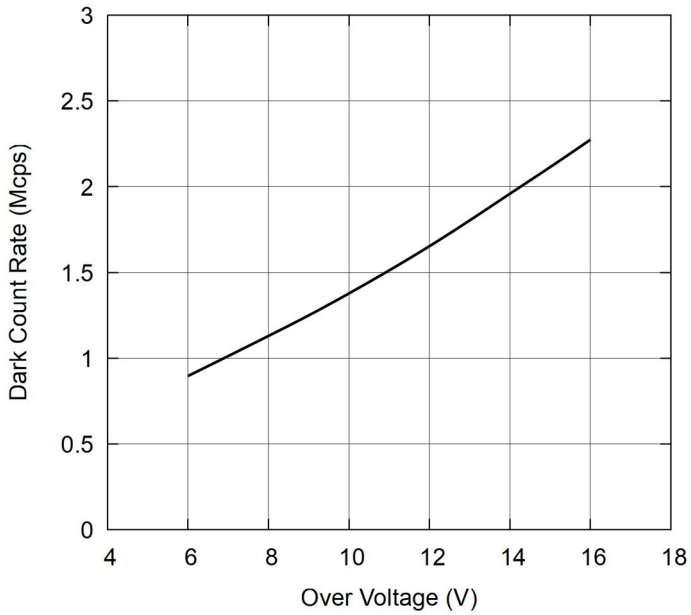

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Figure 10: Gain vs. OV

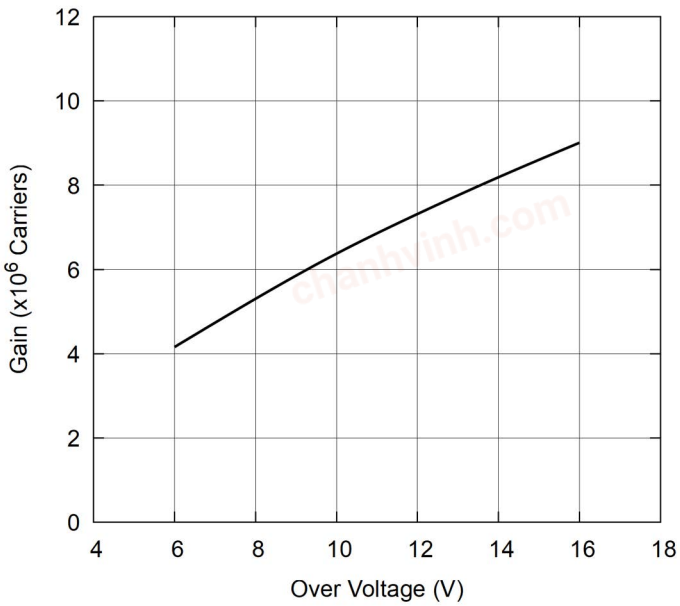


Figure 11: Correlated Noise vs. OV

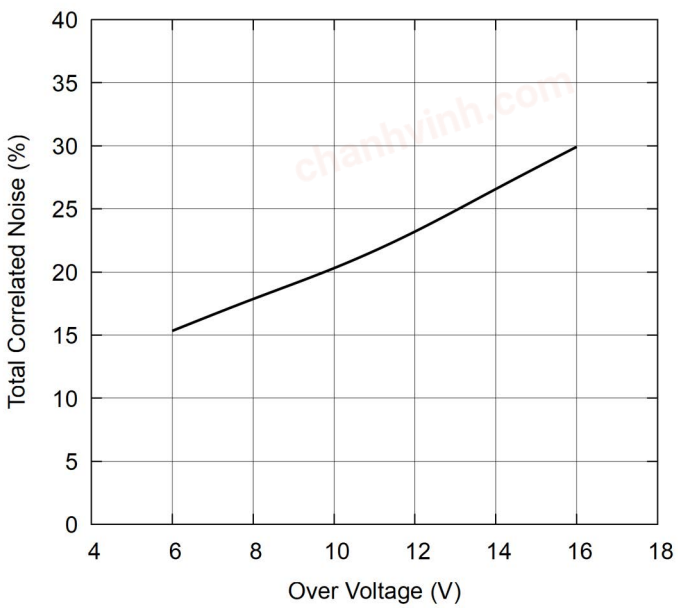
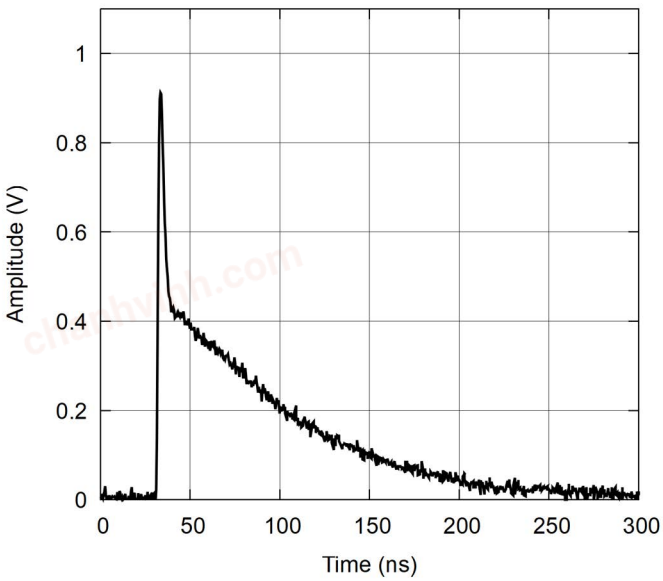


Figure 12: Example Signal Measured at 12V OV



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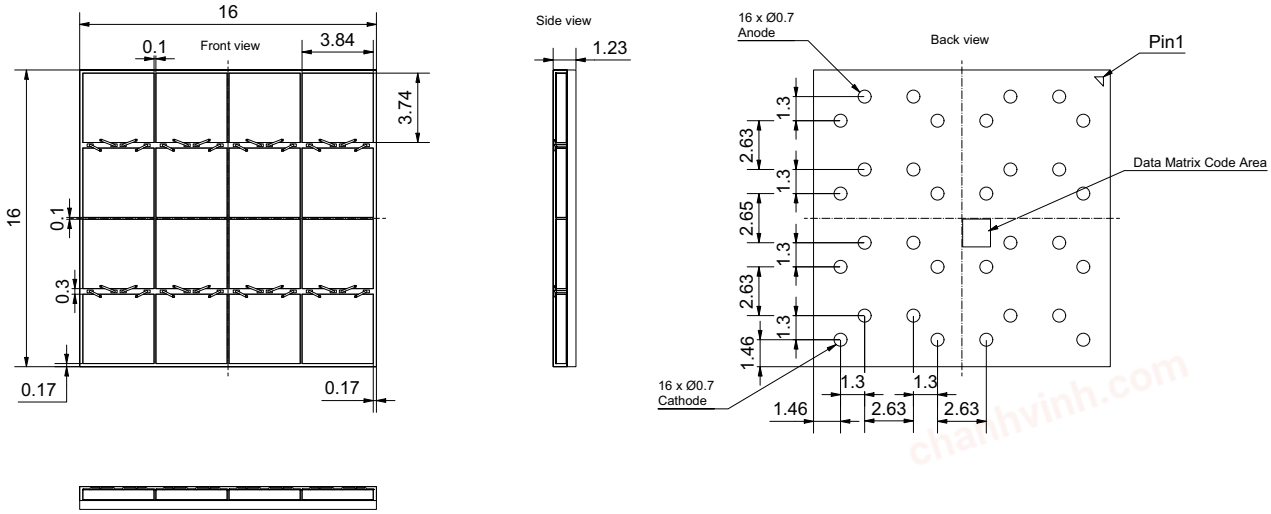
Array Specification

The array consists of 16 wire-bonded SiPM dies arranged in a 4×4 matrix with a package fill factor of 84% (active area versus total package area).

Parameter	Symbol	12V OV			Unit
		Min.	Typ.	Max.	
Dark current sum at 12V OV	ΣI_D	—	53	—	µA

Mechanical Data – Package Outline

Figure 13: Package Outline Drawing (dimensions in mm, numbers rounded to two decimal places)



NOTE:

1. Dimensions are in millimeters.
2. Nominal values rounded to two decimal places – Suppression of following zeros.

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